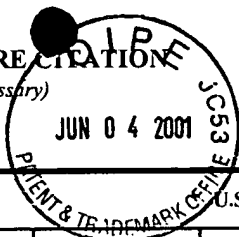


**INFORMATION DISCLOSURE STATEMENT**  
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Docket Number (Optional) <b>1382/005</b>		Application Number
Applicant(s) <b>Lebouitz et al.</b>		
Filing Date <b>April 19, 2001</b>	Group Art Unit	

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*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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							YES	NO
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<i>pl</i>	—	02187025	07/23/90	Japan				
<i>pl</i>	—	11145067	05/28/99	Japan				
<i>pl</i>	—	11204509	07/30/99	Japan				
<i>pl</i>	—	11265878	09/28/99	Japan				

**OTHER DOCUMENTS** (Including Author, Title, Date, Pertinent Pages, Etc.)

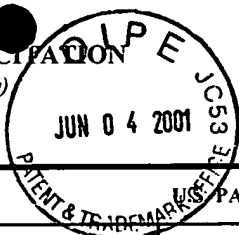
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# INFORMATION DISCLOSURE CITATION

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Docket Number (Optional)

1382/005

Application Number

Applicant(s)

Lebouitz et al.

Filing Date

April 19, 2001

Group Art Unit

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*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

## FOREIGN PATENT DOCUMENTS

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							YES	NO

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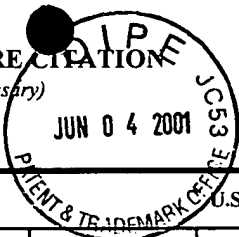
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7-6-07

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Docket Number (Optional)  
1382/005

Application Number  
09/839,763

Applicant(s)  
Leboutiz et al.

Filing Date  
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U.S. PATENT DOCUMENTS

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	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
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**Application Number**  
**09/839,763**

**Filing Date**  
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**DATE CONSIDERED**

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1382/005

**09/839,763**

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**EXAMINER**

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